Notice of Allowability	Application No.	Applicant(s)	
	10/707,083	LU ET AL.	
	Examiner	Art Unit	
	Luan Thai	2829	
	Luaii IIIai	2029	
The MAILING DATE of this communication appeal All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED or other appropriate comments. This application is	in this application. If not included nunication will be mailed in due cou	urse. <b>THIS</b>
1. This communication is responsive to			
2. The allowed claim(s) is/are 1-22.			
3. The drawings filed on 20 November 2003 are accepted by	the Examiner.		
4. Acknowledgment is made of a claim for foreign priority una a) All b) Some* c) None of the:		) or (f).	
1. Certified copies of the priority documents have			
2. Certified copies of the priority documents have been received in Application No			
3. Copies of the certified copies of the priority documents have been received in this national stage application from the			
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:	•	·	
Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		le a reply complying with the requir	ements
5. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give			ICE OF
6. CORRECTED DRAWINGS (as "replacement sheets") mus	t be submitted.		
(a) ☐ including changes required by the Notice of Draftspers	on's Patent Drawing Revi	ew ( PTO-948) attached	
1)  hereto or 2)  to Paper No./Mail Date			
(b) including changes required by the attached Examiner's Paper No./Mail Date	s Amendment / Comment	or in the Office action of	
Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the			ck) of
7. DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT I			e the
Attachment(s) 1. ⊠ Notice of References Cited (PTO-892)	E [] Notice of	Information (DTO 4	50)
<ol> <li>Notice of References Cited (P10-892)</li> <li>Divide of Draftperson's Patent Drawing Review (PT0-948)</li> </ol>		Informal Patent Application (PTO-1	52)
2.     Notice of Dialiperson's Faterit Diawing Neview (F10-946)		Summary (PTO-413), o./Mail Date	
3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date	8), 7.   Examiner	s Amendment/Comment	
4.   Examiner's Comment Regarding Requirement for Deposit		s Statement of Reasons for Allowa	nce
of Biological Material	9.  Other		
Marlinan			
PRIMARY EXAMIN	IER W/so/	Oq	

## **DETAILED ACTION**

- 1. Claims 1-12 are allowed.
- 2. The following is an examiner's statement of reasons for allowance:

The cited art (e.g., U.S. Pat. No. 5,741,740 to Jang et al.) taken either singly or in combination with other prior arts fails to anticipate or fairly suggest at least, among others, the method steps of: a) removing a portion of the first dielectric layer and open up the apertures to form a plurality of openings, performing an etching process to increase the width of the openings, and forming a second dielectric layer over the first dielectric layer to fill the openings completely, as recited in claim 1; b) removing a portion of the first dielectric layer to open up the apertures and form a plurality of openings, removing a section of the first dielectric layer off the sidewalls of the openings so that a width of the opening is increased, forming a second dielectric layer over the first dielectric layer to fill the openings completely, as recited in claim 9; and c) removing a portion of the first dielectric layer to open up the aperture and form a second opening, removing a section of the first dielectric layer off the sidewalls of the second opening to increase a width of the second opening, and forming a second dielectric layer over the first dielectric layer to fill the second opening completely, as recited in claim 16.

3. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Art Unit: 2829

4. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Luan Thai whose telephone number is 571-272-1935. The examiner can normally be reached on 6:45 AM - 4:15 PM, Monday to Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael Tokar can be reached on 571-272-1812. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <a href="http://pair-direct.uspto.gov">http://pair-direct.uspto.gov</a>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Uharlman Luan 7kai

Primary Examiner Art Unit 2829 October 30, 2004